

**AMENDMENTS TO THE SPECIFICATION:**

Please replace the paragraph beginning at page 5, line 15, with the following rewritten paragraph:

--Highly preferred precursor source mixtures comprised of at least one alkyl-containing compound include: trimethyl-, triethyl-, triisobutyl-, tri-n-propyl-, triisopropyl-, tri-n-butyl-, trineopentyl-, or ethyldimethyl-B, Al, Ga, In, As or Sb; tetramethyl-, tetraethyl-, tetraphenyl-, or tetra-n-butyl-Si, Ge, Sn, or Pb; dimethyl-, diethyl-, or diisobutyl-B, Al, Ga, In, As or Sb, hydride, chloride, fluoride, bromide, iodide, Cp, amide, dimethylamide or azide; triethyl-, triisobutyl-, tri-n-propyl-, triisopropyl-, tri-n-butyl- or ethyldimethyl-B, Al, Ga, In, As or Sb trimethylamine, diethylmethylamine, dimethylethylamine, or triethylamine; dimethyl- or diethyl-Zn, Cd, or Hg;(neopentyl)<sub>4</sub>Cr; Et<sub>3</sub>Pb(neopentoxy); Cp<sub>2</sub>Me<sub>2</sub>Zr; (MeNC)<sub>2</sub>PtMe<sub>2</sub>; or CpIr(C<sub>2</sub>H<sub>4</sub>)<sub>2</sub> where Cp is cyclopentadienyl or substituted cyclopentadienyl wherein replacement of H substituent(s) with methyl, ethyl, isopropyl, n-butyl, sec-butyl, tert-butyl, trimethylsilyl or other like substituents dissolved, emulsified or suspended in a C<sub>5</sub>-C<sub>12</sub> alkane liquid. Other preferred precursor source mixtures are comprised of at least one alkyl-containing compound including, but not limited to: a trimethyl or triethyl substituent in emulsified or suspended in a liquid composed essentially of a C<sub>5</sub>-C<sub>12</sub> alkane liquid with optionally added methane or ethane (no more than 30% by volume of the inert liquid).--